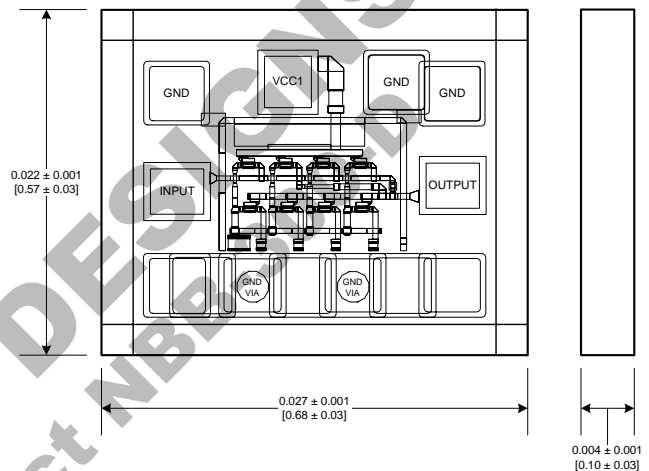


Typical Applications

- Narrow and Broadband Commercial and Military Radio Designs
- Linear and Saturated Amplifiers
- Gain Stage or Driver Amplifiers for MWRadio/Optical Designs

Product Description

The NDA-410-D InGaP/GaAs HBT MMIC distributed amplifier is a low-cost, high-performance solution for high frequency RF, microwave, or optical amplification needs. This 50Ω matched distributed amplifier is based on a reliable HBT proprietary MMIC design, providing unsurpassed performance for small-signal applications. Designed with an external bias resistor, the NDA-410-D provides flexibility and stability. In addition, the NDA-410-D chip was designed with an additional ground via to enable low junction temperature operation. NDA-series of distributed amplifiers provide design flexibility by incorporating AGC functionality into their designs.



Optimum Technology Matching® Applied

- | | | |
|---|-----------------------------------|---------------------------------------|
| <input type="checkbox"/> Si BJT | <input type="checkbox"/> GaAs HBT | <input type="checkbox"/> GaAs MESFET |
| <input type="checkbox"/> Si Bi-CMOS | <input type="checkbox"/> SiGe HBT | <input type="checkbox"/> Si CMOS |
| <input checked="" type="checkbox"/> InGaP/HBT | <input type="checkbox"/> GaN HEMT | <input type="checkbox"/> SiGe Bi-CMOS |

Package Style: Die

Features

- Reliable, Low-Cost HBT Design
- 12.0dB Gain, +15.5dBm P1dB @2GHz
- High P1dB of InGaP +14.8dBm @6.0GHz and +13.5dBm @11.0GHz
- Fixed Gain or AGC Operation
- 50Ω I/O Matched for High Freq. Use

Ordering Information

NDA-410-D InGaP/GaAs HBT MMIC Distributed Amplifier DC to 11GHz - Die Only (100 pieces minimum order)

RF Micro Devices, Inc.
7628 Thorndike Road
Greensboro, NC 27409, USA

Tel (336) 664 1233
Fax (336) 664 0454
<http://www.rfmd.com>

Functional Block Diagram

NDA-410-D

Absolute Maximum Ratings

Parameter	Rating	Unit
RF Input Power	+15	dBm
Power Dissipation	300	mW
Device Current, I _{CC1}	42	mA
Device Current, I _{CC2}	42	mA
Junction Temperature, T _j	200	°C
Operating Temperature	-45 to +85	°C
Storage Temperature	-65 to +150	°C

Exceeding any one or a combination of these limits may cause permanent damage.



Caution! ESD sensitive device.

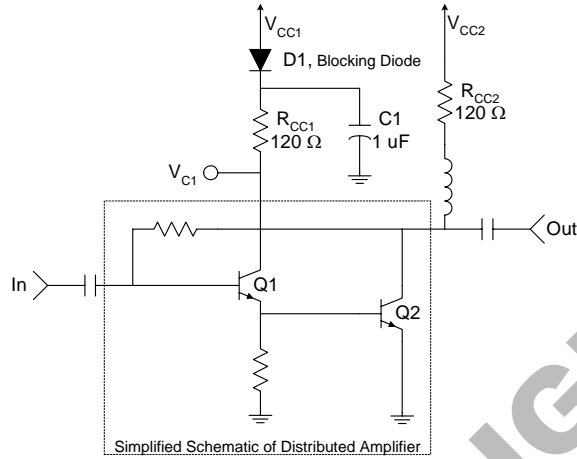
RF Micro Devices believes the furnished information is correct and accurate at the time of this printing. However, RF Micro Devices reserves the right to make changes to its products without notice. RF Micro Devices does not assume responsibility for the use of the described product(s).

Parameter	Specification			Unit	Condition
	Min.	Typ.	Max.		
Overall					V _{CC1} =+10V, V _{CC2} =+10V, V _{C1} =+4.7V, V _{C2} =+2.98V, I _{CC1} =29mA, I _{CC2} =36mA, Z ₀ =50Ω, T _A =+25°C
Small Signal Power Gain, S ₂₁	12.0	13.0		dB	f=0.1GHz to 4.0GHz
		13.0		dB	f=4.0GHz to 6.0GHz
		13.0		dB	f=6.0GHz to 8.0GHz
Input and Output VSWR	9.0	10.0		dB	f=8.0GHz to 11.0GHz
		1.35:1			f=0.1GHz to 4.0GHz
		2.3:1			f=4.0GHz to 8.0GHz
		3.50:1			f=8.0GHz to 11.0GHz
Bandwidth, BW		11.0		GHz	BW3 (3dB)
Output Power @ 1dB Compression		15.5		dBm	f=2.0GHz
		14.8		dBm	f=6.0GHz
		13.5		dBm	f=11.0GHz
Noise Figure, NF		5.0		dB	f=2.0GHz
Third Order Intercept, IP3		+25.5		dBm	f=2.0GHz
Reverse Isolation, S ₁₂		-16.0		dB	f=0.1GHz to 11.0GHz
Output Device Voltage, V _{C2}	2.70	2.98	3.20	V	
AGC Control Voltage, V _{C1}		4.7		V	
Gain Temperature Coefficient, δG _T /δT		-0.0015		dB/°C	
MTTF versus Junction Temperature					
Case Temperature		85		°C	
Junction Temperature		144		°C	
MTTF		>1,000,000		hours	
Thermal Resistance					
θ _{JC}		242		°C/W	$\frac{J_T - T_{CASE}}{V_D \cdot I_{CC}} = \theta_{JC} (^{\circ}C/Watt)$

Suggested Voltage Supply: V_{CC1}≥4.7V, V_{CC2}≥5.0V

Typical Bias Configuration

Application notes related to biasing circuit, device footprint, and thermal considerations are available on request.



Bias Resistor Selection

R_{CC1}:
 For 4.7V < V_{CC1} < 5.0V
 R_{CC1} = 0 Ω
 For 5.0V < V_{CC1} < 10.0V
 R_{CC1} = V_{CC1} - 4.7 / 0.029 Ω

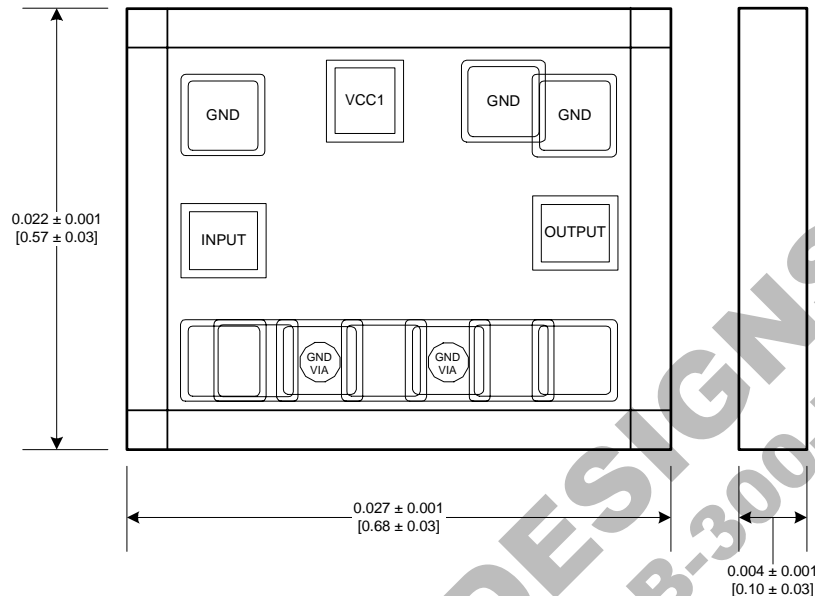
R_{CC2}:
 For 5.0V < V_{CC2} < 10.0V
 R_{CC2} = V_{CC2} - 2.98 / 0.036 Ω

Typical Bias Parameters for V_{CC1} = V_{CC2} = 10V:

V _{CC1} (V)	V _{CC2} (V)	I _{CC1} (mA)	V _{C1} (V)	R _{CC1} (Ω)	I _{CC2} (mA)	V _{C2} (V)	R _{CC2} (Ω)
10	10	29	4.75	180	36	2.98	195

Chip Outline Drawing - NDA-410-D

Chip Dimensions: 0.027" x 0.022" x 0.004"



Sales Criteria - Unpackaged Die

Die Sales Information

- All segmented die are sold 100% DC-tested. Testing parameters for wafer-level sales of die material shall be negotiated on a case-by-case basis.
- Segmented die are selected for customer shipment in accordance with RFMD Document #6000152 - Die Product Final Visual Inspection Criteria¹.
- Segmented die has a minimum sales volume of 100 pieces per order. A maximum of 400 die per carrier is allowable.

Die Packaging

- All die are packaged in GelPak ESD protective containers with the following specification: O.D.=2"X2", Capacity=400 Die (20X20 segments), Retention Level=High(X8).
- GelPak ESD protective containers are placed in a static shield bag. RFMD recommends that once the bag is opened the GelPak/s should be stored in a controlled nitrogen environment. Do not press on the cover of a closed GelPak, handle by the edges only. Do not vacuum seal bags containing GelPak containers.
- Precaution must be taken to minimize vibration of packaging during handling, as die can shift during transit².

Package Storage

- Unit packages should be kept in a dry nitrogen environment for optimal assembly, performance, and reliability.
- Precaution must be taken to minimize vibration of packaging during handling, as die can shift during transit².

Die Handling

- Proper ESD precautions must be taken when handling die material.
- Die should be handled using vacuum pick-up equipment, or handled along the long side with a sharp pair of tweezers. Do not touch die with any part of the body.
- When using automated pick-up and placement equipment, ensure that force impact is set correctly. Excessive force may damage GaAs devices.

Die Attach

- The die attach process mechanically attaches the die to the circuit substrate. In addition, the utilization of proper die attach processes electrically connect the ground to the trace on which the chip is mounted. It also establishes the thermal path by which heat can leave the chip.
- Die should be mounted to a clean, flat surface. Epoxy or eutectic die attach are both acceptable attachment methods. Top and bottom metallization are gold. Conductive silver-filled epoxies are recommended. This procedure involves the use of epoxy to form a joint between the backside gold of the chip and the metallized area of the substrate.
- All connections should be made on the topside of the die. It is essential to performance that the backside be well grounded and that the length of topside interconnects be minimized.
- Some die utilize vias for effective grounding. Care must be exercised when mounting die to preclude excess run-out on the topside.

Die Wire Bonding

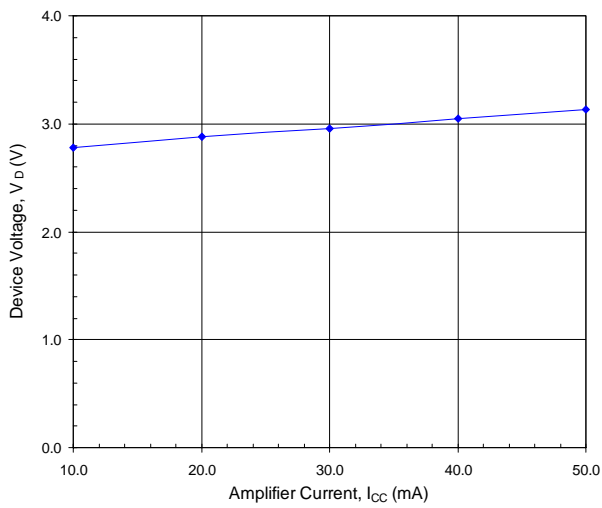
- Electrical connections to the chip are made through wire bonds. Either wedge or ball bonding methods are acceptable practices for wire bonding.
- All bond wires should be made as short as possible.

Notes

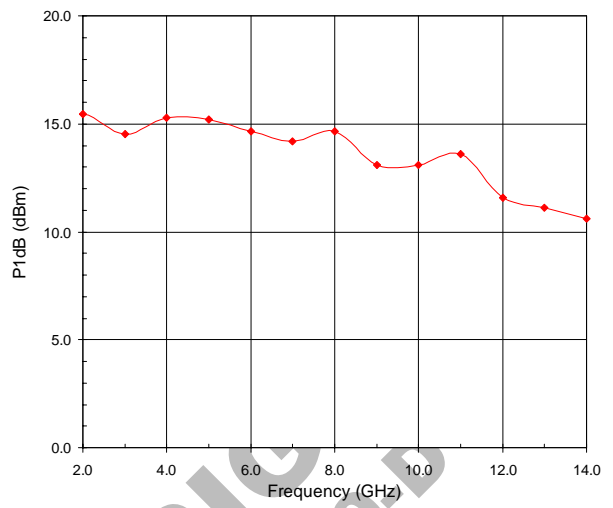
¹RFMD Document #6000152 - Die Product Final Visual Inspection Criteria. This document provides guidance for die inspection personnel to determine final visual acceptance of die product prior to shipping to customers.

²RFMD takes precautions to ensure that die product is shipped in accordance with quality standards established to minimize material shift. However, due to the physical size of die-level product, RFMD does not guarantee that material will not shift during transit, especially under extreme handling circumstances. Product replacement due to material shift will be at the discretion of RFMD.

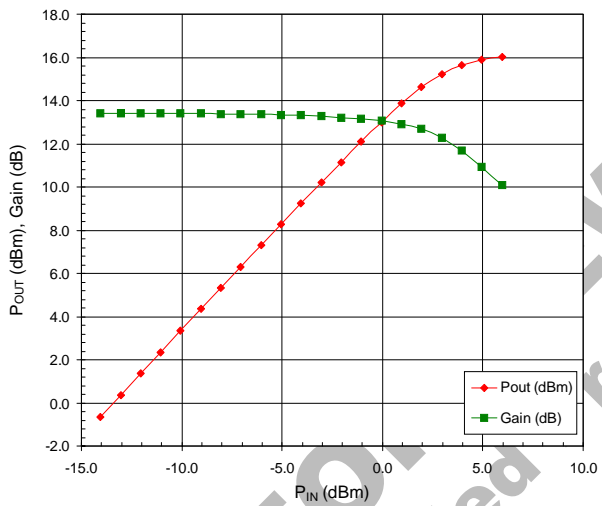
Device Voltage versus Amplifier Current



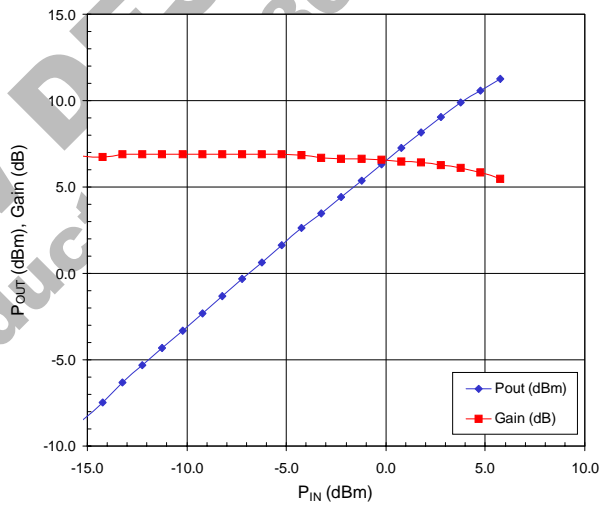
P1dB versus Frequency at 25°C



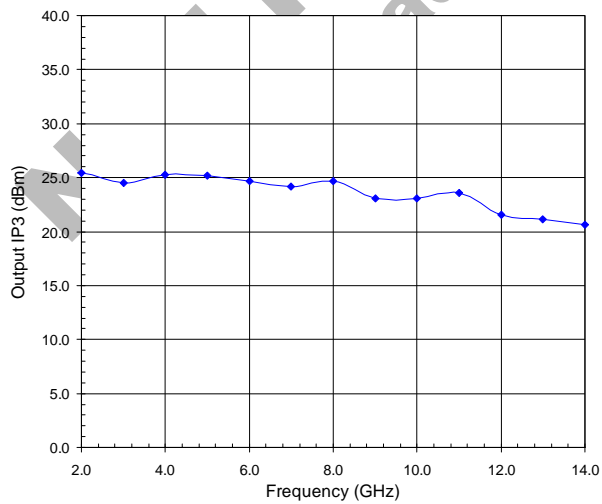
$P_{OUT}/Gain$ versus P_{IN} at 6 GHz



$P_{OUT}/Gain$ versus P_{IN} at 14 GHz



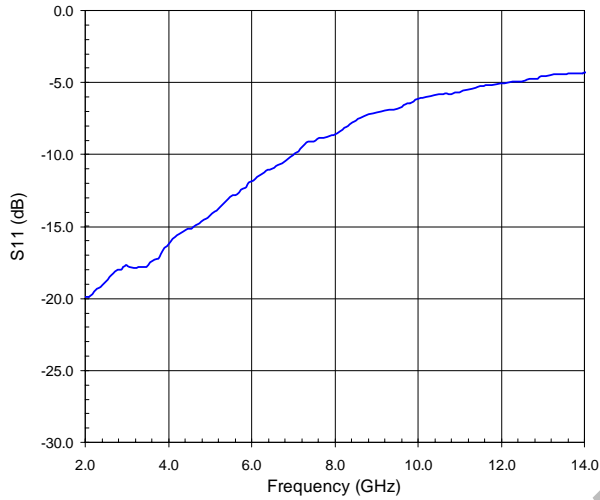
Third Order Intercept versus Frequency at 25°C



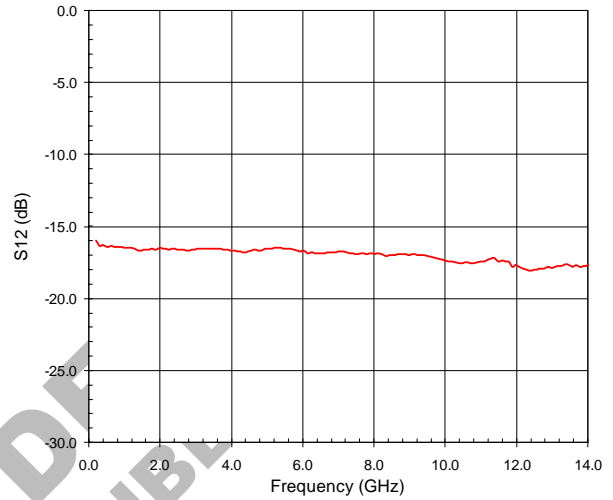
Note: The s-parameter gain results shown below include device performance as well as evaluation board and connector loss variations. The insertion losses of the evaluation board and connectors are as follows:

- 1 GHz to 4GHz=-0.06dB
- 5GHz to 9GHz=-0.22dB
- 10GHz to 14GHz=-0.50dB
- 15GHz to 20GHz=-1.08dB

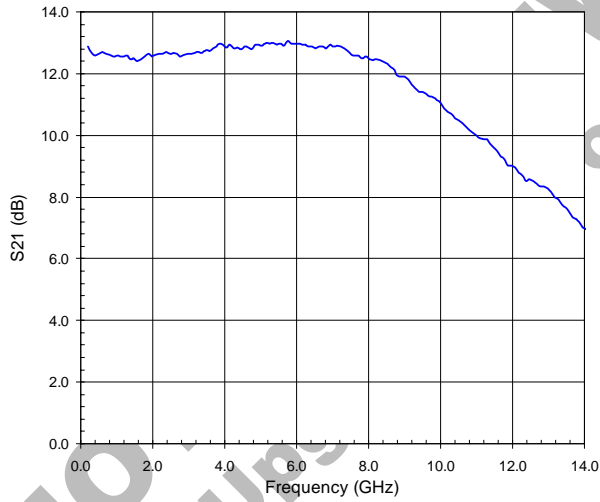
S11 versus Frequency



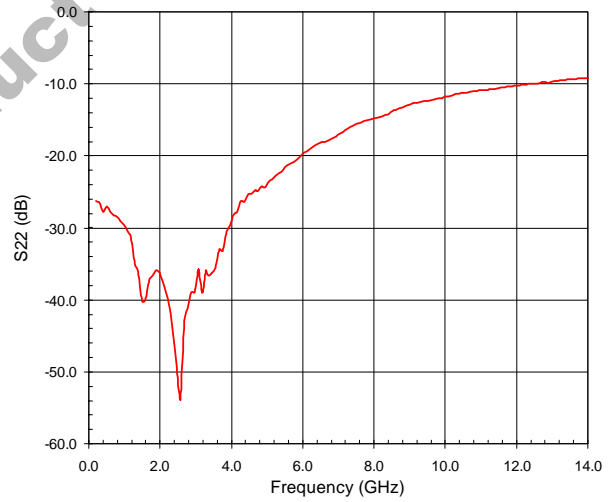
S12 versus Frequency



S21 versus Frequency



S22 versus Frequency



NOT FOR NEW DESIGNS
See Upgraded Product **NBB-300-D**